

China Semiconductor Technology International Conference (CSTIC) 2020 Summary

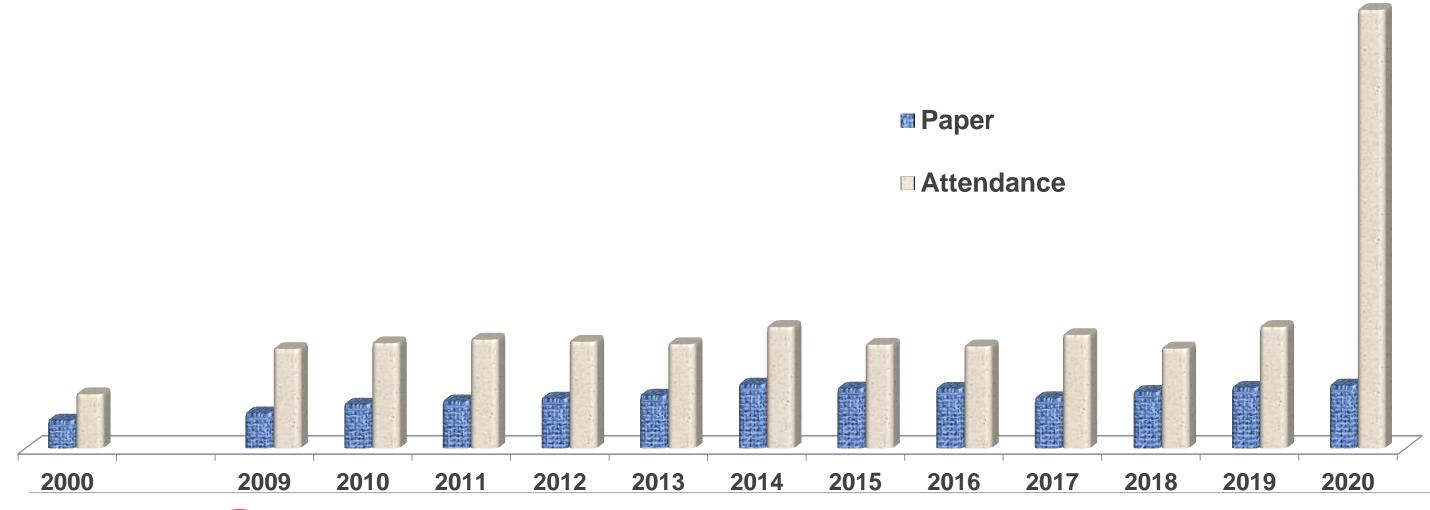
June 26-July 24





2020 CSTIC - First Online Virtual Conference

- Largest and most comprehensive, influential annual industrial semiconductor technology conference in China and Asia
- Record-breaking 430 abstracts, 2746 attendees, and 12630 clicks at v.semi.org.cn

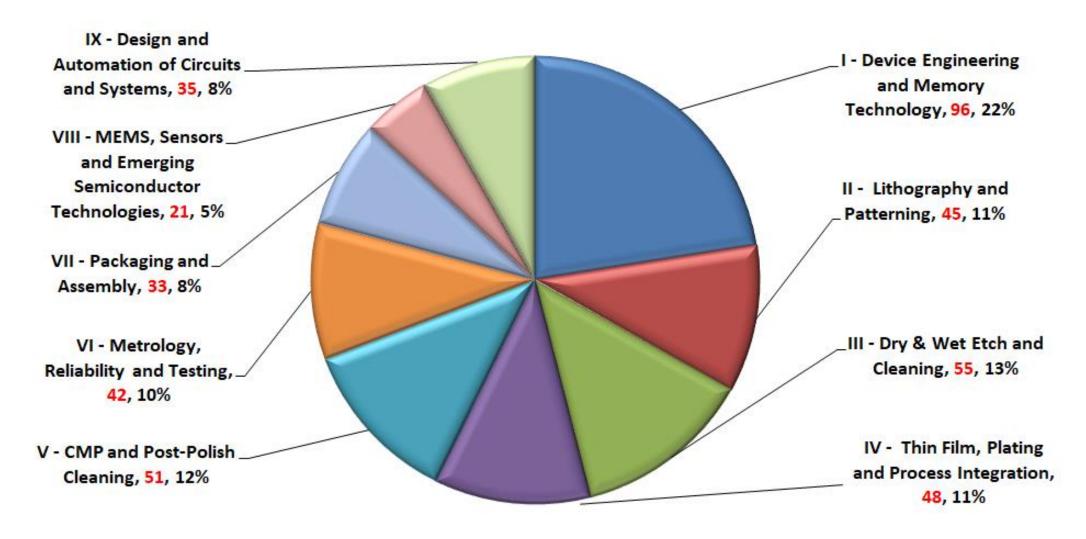








CSTIC Symposium Platform



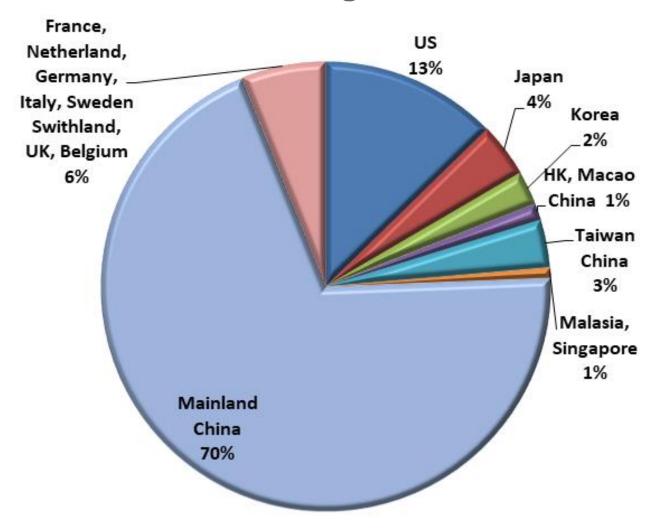
220 Full-Length Manuscripts Published in IEEE Xplore (El cited)





International Collaboration

• 430 submissions from 17 countries and regions



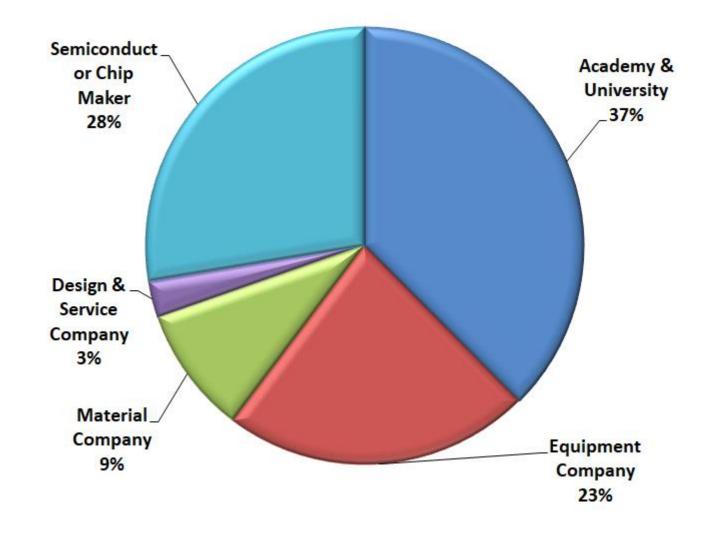






Industry Collaboration

63% abstracts from industry

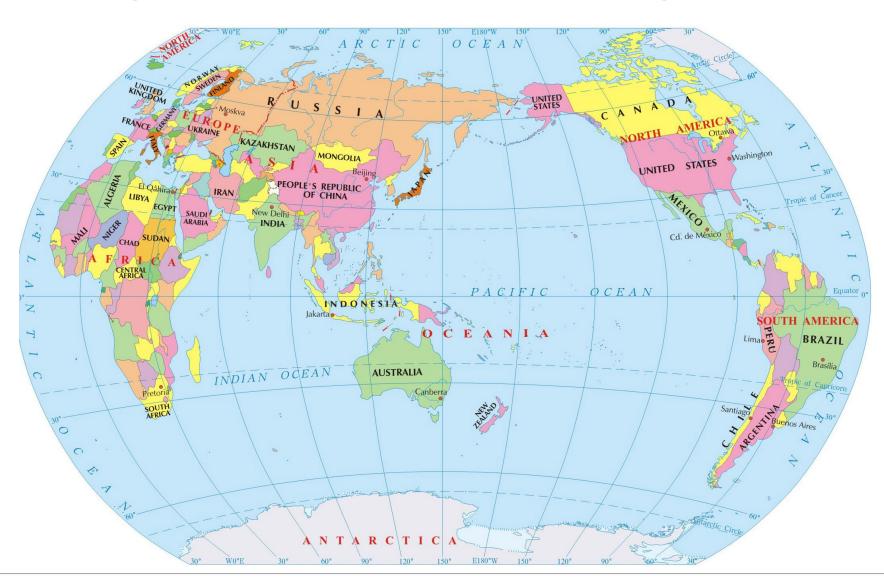






Registration Worldwide

2746 registration from 20 countries and regions



Belgium

Canada

China Hong Kong

China Macau

China Mainland

China Taiwan Region

Finland

France

Germany

Italy

Japan

Korea

Malaysia

Netherlands

Singapore

South Africa

Sweden

Switzerland

United Kingdom

United States of America









Next Big Frontiers - Chiplet Integration and More

Dr. Doug Yu Vice President, R&D, TSMC



Opportunities in Advanced Packaging for Heterogeneous Integration

Dr. Ravi Mahajan Fellow, Intel



EUV Lithography - the Road to High-Volume Manufacturing

Dr. Anthony Yen Vice President, ASML



Integrated Materials Solutions: A Path Forward For Moore's Law

Dr. Sanjay Natarajan Vice President, Applied Materials







Conference Schedule

Poster Session: June 26-July 24 156 posters

Tutorials: June 28-July 24 5 tutorials

Plenary Session,9 Symposia and Panel Discussion 157 videos

Symp I: Device Engineering and Memory Technology

Symp. II: Lithography and Patterning

Symp. III: Dry &Wet Etch and Cleaning

Symp. IV: Thin Film, Plating and Process Integration

Symp. V: CMP and Post-Polish Cleaning

Symp. VI: Metrology, Reliability and Testing

Symp. VII: Packaging and Assembly

Symp. VIII: MEMS, Sensors and Emerging Semiconductor Technologies

Symp. IX: Design and Automation of Circuits and Systems



Dr. Tak H. Ning Fellow,



Principal Member of Technical Staff, IMEC





Dr. Dechao Guo Senior Manager, Advanced Device Research, IBM Research





Prof. Stacey F. Bent
Professor,
Stanford University



Dr. AbdelKarim Mercha
Technical Director,





2020

中国半导体技术大会



Dr. Hakaru Mizoguchi Exective Vice President and CTO, Gigaphoton



Mr. Terrance Lee
Vice President,
Applied Materials





Dr. Hu Chuan

Chief Expert,
Guangdong Academy
of Sciences



Prof. Vijavkrishnar

Distinguished Professor Pennsylvania State

Narayanan

University

Dr. Bill Bottoms
Chairman & CEO,



Dr. Jeongdong Choe Senior Technical Fellow, Technicalts



Prof. Hidetoshi Onodera Professor, Kyoto University









Panel Discussion: System Integration through 3D and Advanced Packaging



Moderator: Dr. Steve X. Liang

- 1.We understand that 3D heterogeneous integration will help extend Moore's law from systems' perspective. Will it be a short-term boost or continuous enhancement node after node?
- 2. What are the key features for 3D and Advance Packaging Integration, TSV pitch, Chip Layers, etc? How small these critical pitches can go and is there a trend like Moore's law to follow?
- 3. 3D package vs. 3D sequential integration comparison in terms of thermal budgets, performance, power management, etc.
- 4. What are the impacts of the 3D and Advance Packaging Integration to the existing OSAT business and supply chains? What are the major opportunities for the existing OSAT business?

Panelists



Dr. Doug Yu Vice President, R&D, TSMC



Dr. Ravi Mahajan Fellow, Intel



Dr. Bill Bottoms CEO, 3MTS







Tutorials

1. Advanced Memory Technologies: MRAM



Dr. Shu-Jen HanSenior Director
HFC Semiconductor Corp.

2. Advanced Memory Technologies: EPCM/3D-PCM



Dr. Yu ZhuExecutive Assistant to CEO,
Jiangsu Advanced Memory Semiconductor (AMS) Co., Ltd

3. Semiconductor Testing Solutions in the Trend of 5G and Al



Liang GeR&D manager and Test strategy leader
Advantest China

4.Heterogeneous Integration And Advanced Packaging



Dr. Bill BottomsChairman and CEO, 3MTS

5.IC Reliability Tests For 5G Applications



Xu Feng
Deputy General Manager & Technology Director
JCET quality test center







Plenary Session and Award Winners















Conference Chair and Co-Chairs



Dr. Steve X. Liang Chair JCET, China



Dr. Qinghuang Lin Exe. Co-Chair Lam, USA



Dr. Ru Huang Co-Chair PKU, China



Dr. Cor Claeys Co-Chair KU Leuven, Belgium



Dr. Hanming Wu
Co-Chair
Zhejiang University
China







Symposium Chairs



Dr. Ru Huang Chair, S-I Peking Univ. China



Dr. Peilin Song Chair, S-VI IBM USA



Dr. Kafai Lai Chair, S-II IBM USA



Dr. Steve X.
Liang
Chair, S-VII
JCET, China



Dr. Ying Zhang Chair, S-III Naura USA



Dr. Qinghuang Lin Chair, S-VIII Lam, USA



Dr. Beichao Zhang Chair, S-IV HFC. China



Dr. Wenjian Yu Chair S-IX Tsinghua University, China



Dr. Xin Ping Qu Chair, S-V Fudan Univ. China



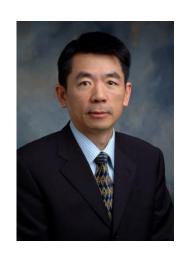
Dr. Hsiang-Lan Lung Poster Chair Macronix, Taiwan, China





Organizing Team





Mr. Lung Chu President SEMI China

Ms. Lily Feng Ms. April Peng Ms. Cheryl Qiu Ms. Mina Chen Mr. Tony Liu

Mr. Jesse Zhang Ms. June Wu Mr. Mortal Li Ms. Hannah Zhao Ms. Louisa Li

SEMI China Team



Dr. Lode Lauwers Vice President IMEC, Belgium







Special Thanks to Sponsors























CSTIC 2021

- Time: March 14-15 (Sunday-Monday)
- Venue: Shanghai International Convention Center (SHICC)
- Call for Papers Deadline: Nov. 15, 2020











Thanks for the Support!







